

FORM PTO 1449 (modified)

U.S. DEPARTMENT OF COMMERCE  
PATENT AND TRADEMARK OFFICE

LIST OF REFERENCES CITED BY APPLICANT(S)  
(Use several sheets if necessary)

ATTY DOCKET NO.

**00839.000449**

APPLICATION NO.

09/982.846

**APPLICANT**

ATSUSHI KOIKE ET AL.

FILING DATE

**October 22, 2001**

GROUP

2813

U.S. PATENT DOCUMENTS

| *EXAMINER<br>INITIAL |  | DOCUMENT<br>NUMBER | DATE     | NAME             | CLASS | SUBCLASS | FILING DATE<br>IF APPROPRIATE |
|----------------------|--|--------------------|----------|------------------|-------|----------|-------------------------------|
| EK                   |  | 5,510,151          | 04/23/96 | Matsuyama et al. | 427   | 509      |                               |
| EK                   |  | 5,130,170          | 07/14/92 | Kanai et al.     | 427   | 38       |                               |
| EK                   |  | 2002-0006476 A1    | 01/17/02 | Yajima et al.    | 427   | 569      | 12/04/00                      |
| EK                   |  | 2002-0009546 A1    | 01/24/02 | Koike et al.     | 427   | 255.27   | 03/28/01                      |
|                      |  |                    |          |                  |       |          |                               |
|                      |  |                    |          |                  |       |          |                               |
|                      |  |                    |          |                  |       |          |                               |
|                      |  |                    |          |                  |       |          |                               |

FOREIGN PATENT DOCUMENTS

| FOREIGN PATENT DOCUMENTS |    |                    |          |         |       |          |                                       |
|--------------------------|----|--------------------|----------|---------|-------|----------|---------------------------------------|
|                          |    | DOCUMENT<br>NUMBER | DATE     | COUNTRY | CLASS | SUBCLASS | TRANSLATION<br>YES/NO/<br>OR ABSTRACT |
| Ek                       | JP | 5-24992            | 02/02/93 | Japan   | —     | —        | Abstract                              |
| Ek                       | JP | 2819031            | 10/30/98 | Japan   | —     | —        | Abstract.                             |
| Ek                       | JP | 2819030            | 10/30/98 | Japan   | —     | —        | Abstract                              |
| Ek                       | JP | 8-97161            | 04/12/96 | Japan   | —     | —        | Yes                                   |
|                          |    |                    |          |         |       |          |                                       |

OTHER DOCUMENT(S) (Including Author, Title, Date, Pertinent Pages, Etc.)

|          |  |
|----------|--|
| EX       | A. Shah et al., "VHF Plasma Deposition: A Comparative Overview," Amorphous Silicon Technology - 1992, v. 258 Materials Research Society Symposium Proceedings 15-26 (1992) |
|          |  |
|          |  |
|          |  |
| EXAMINER | DATE CONSIDERED  |
| Eis Kuli | 12/16/02   |

\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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